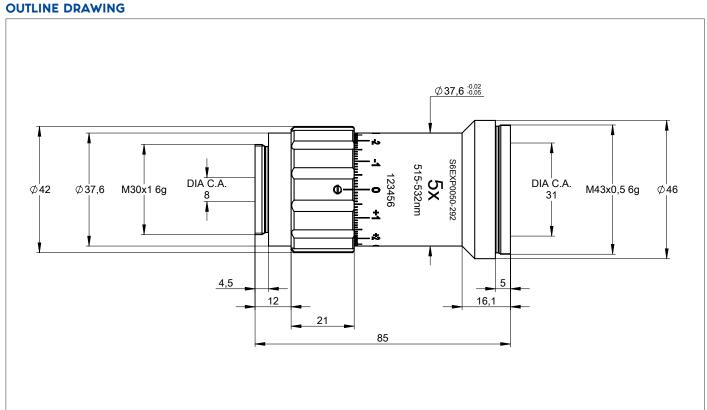
DATA SHEET

S6EXPO050-292

BEAMEXPANDER MAGNIFICATION 5.0 FOR 515 - 545 nm **FUSED SILICA**





All information contained in this data sheet is for information purposes only and is not binding. The content is subject to change at any time without notification, all information without guarantee. We reserve the right to make constructional changes in the course of product improvement. Copyright @ Sill Optics GmbH · All rights reserved

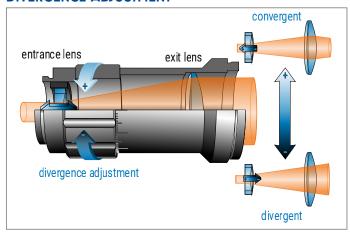


DATA SHEET

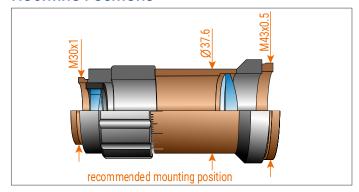
SPECIFICATIONS

article number	S6EXP0050-292
design wavelength [nm]	532
magnification factor	5.0
divergence adjustable	yes
optical principle	Galilei (no internal focus)
pointing stability [mrad]	<1
clear input aperture [mm]	8.0
clear output aperture [mm]	31.0
recommended beam-Ø [mm]1)	4.5
total number of lenses	3
total transmission [%]	> 98
lens material	fused silica
LIDT (coating) [J/cm²]	2.5 J/cm² per 1ns pulse at 50Hz
SP and USP usable	yes
SP and USP usable, reversed usage	no
mounting thread	M30x1
weight [kg]	0.2
accessory	S6MEC0107 - adapter M30x1 to C-mount

DIVERGENCE ADJUSTMENT



MOUNTING POSITIONS



REMARKS

¹⁾clipped at $1/e^2$; wavefront error on axis (PV) < $\lambda/10$ (value provided by design) magnification (reversed mode) = 1 / magnification (regular mode)

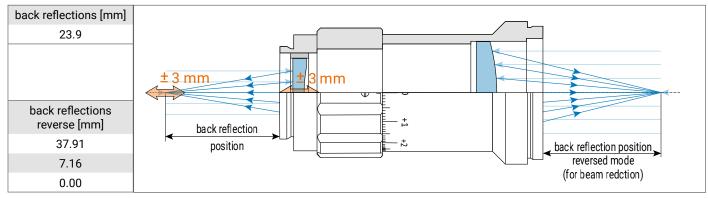
divergence adjustement = 0 → collimated input beam results in collimated output beam

maximum divergence adjustment is ± 3 mm

RoHS compliant

length at divergence setting "0" stated in the drawing - length extension of max. 3 mm is possible

BACK REFLECTION POSITION



All information contained in this data sheet is for information purposes only and is not binding. The content is subject to change at any time without notification, all information without guarantee. We reserve the right to make constructional changes in the course of product improvement. Copyright © Sill Optics GmbH • All rights reserved

